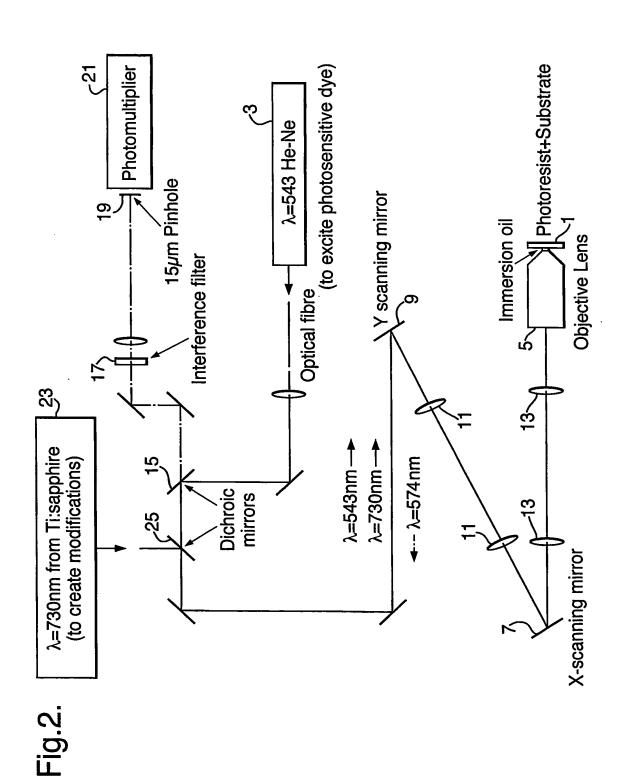
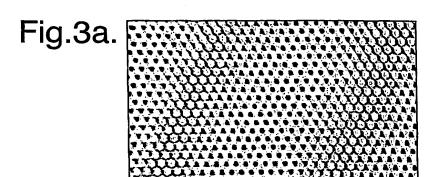
1/3

Fig.1. 101 Prepare photosensitive material 103 Make first exposure using interference pattern 105 Image latent exposure pattern to locate its position 107 Make further exposures to modify pattern Develop photosensitive material to create structures defined by exposures Use as template Use as to define optical element optical element

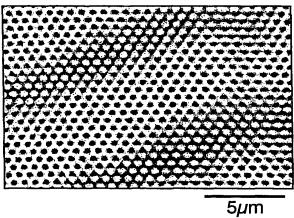


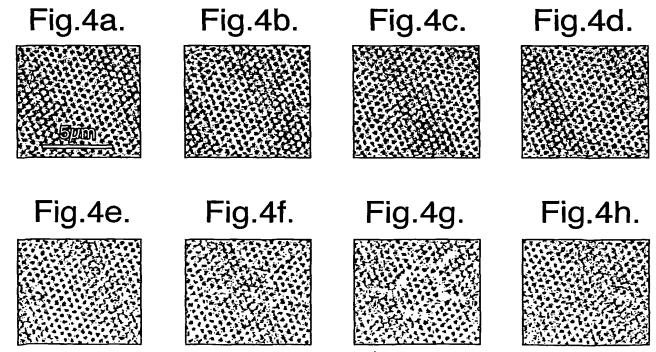
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3/3









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